**What Is Claimed Is:**

1. A fuse structure, comprising:

a substrate;

a first conductive layer formed on part of the substrate, wherein a layout of the first conductive layer starts from a fourth vertical line along a first horizontal line in a second direction, turning in an intersection of a second vertical line and a second horizontal line;

a second conductive layer formed on part of the substrate, wherein a layout of the second conductive layer starts from a first vertical line along a third horizontal line in a first direction, turning in an intersection of a third vertical line and a fourth horizontal line;

a first dielectric layer formed on the first conductive layer, the second conductive layer and the substrate;

a third conductive layer formed on the part of the first dielectric layer, wherein a layout of the third conductive layer starts from the first vertical line along the third horizontal line in the first direction, turning in an intersection of the third vertical line and the second horizontal line;

a fourth conductive layer formed on the part of the first dielectric layer, wherein a layout of the fourth conductive layer starts from the fourth vertical line along a fifth horizontal line in the second direction, turning in an intersection of the second vertical line and the fourth horizontal line;

a second dielectric layer formed on the third conductive layer, the fourth conductive layer and the first dielectric layer;

a fifth conductive layer formed on part of the second dielectric layer, wherein a layout of the fifth conductive layer starts from the first vertical line along the fourth horizontal line in the first direction and extends to the second vertical line;

a sixth conductive layer formed on part of the second dielectric layer, wherein a layout of the sixth conductive layer starts from the fourth vertical line along the fourth horizontal line in the second direction and extends to the third vertical line;

a seventh conductive layer formed on part of the second dielectric layer, wherein a layout of the seventh conductive layer starts from the first vertical line along the third horizontal line and extends to the fourth vertical line;

a eighth conductive layer formed on part of the dielectric layer, wherein a layout of the eight conductive layer starts from the first vertical line along the second horizontal line in the first direction and extends to the second vertical line;

a ninth conductive layer formed on part of the second dielectric layer, a layout of the ninth conductive layer starts from the fourth vertical line along the second horizontal line in the second direction and extends to the third vertical line;

a tenth conductive layer formed on part of the second dielectric layer, a layout of the tenth conductive

layer starts from the first vertical line along the first horizontal line and extends to the fourth vertical line;

a first conductive plug formed on an intersection of the second vertical line and the second horizontal line to penetrate the first dielectric layer and the second dielectric layer to electrically connected to the first conductive layer and the eighth conductive layer;

a second conductive plug formed on an intersection of the third vertical line and the second horizontal line to penetrate the second dielectric layer to electrically connected to the third conductive layer and the ninth conductive layer;

a third conductive plug formed on an intersection of the second vertical line and the fourth horizontal line to penetrate the second dielectric layer to electrically connected to the fourth conductive layer and the fifth conductive layer; and

a fourth conductive plug formed on an intersection of the third vertical line and the fourth horizontal line to penetrate the first dielectric layer and the second dielectric layer to electrically connected to the second conductive layer and the sixth conductive layer.

2. The fuse structure as claimed in claim 1, wherein the first horizontal line, the second horizontal line, the third horizontal line, the fourth horizontal line and the fifth horizontal line are arranged in order, the first vertical line, the second vertical line, the third vertical line and the fourth

vertical line are arranged in order, the distance between the first vertical line and the vertical line longer than the distance between the second vertical line and the third vertical line, and the distance between the third vertical line and the fourth vertical line is longer than the distance between the second vertical line and the third vertical line 91.

3. The fuse structure as claimed in claim 1, wherein the first conductive layer, the second conductive layer, the third conductive layer and the fourth conductive layer are tungsten or polysilicon.

4. The fuse structure as claimed in claim 1, wherein the fifth conductive layer, the sixth conductive layer, the seventh conductive layer, the eighth conductive layer, the ninth conductive layer and tenth conductive layer are aluminum, copper-aluminum alloy or polysilicon.

5. The fuse structure as claimed in claim 1, wherein the first conductive plug, the second conductive plug, the third conductive plug and the fourth conductive plug are tungsten or polysilicon.

6. The fuse structure as claimed in claim 1, wherein the first dielectric layer and the second dielectric layer are SiO2.

7. A fuse window having a plurality of fuse structures, each comprising:

a substrate;

a first conductive layer formed on part of the substrate, wherein a layout of the first conductive layer starts from a fourth vertical line along a first horizontal line in a second direction, turning in an intersection of a second vertical line and a second horizontal line;

a second conductive layer formed on part of the substrate, wherein a layout of the second conductive layer starts from a first vertical line along a third horizontal line in a first direction, turning in an intersection of a third vertical line and a fourth horizontal line;

a first dielectric layer formed on the first conductive layer, the second conductive layer and the substrate;

a third conductive layer formed on the part of the first dielectric layer, wherein a layout of the third conductive layer starts from the first vertical line along the third horizontal line in the first direction, turning in an intersection of the third vertical line and the second horizontal line;

a fourth conductive layer formed on the part of the first dielectric layer, wherein a layout of the fourth conductive layer starts from the fourth vertical line along a fifth horizontal line in the second direction, turning in an intersection of the second vertical line and the fourth horizontal line;

a second dielectric layer formed on the third conductive layer, the fourth conductive layer and the first dielectric layer;

a fifth conductive layer formed on part of the second dielectric layer, wherein a layout of the fifth conductive layer starts from the first vertical line along the fourth horizontal in the first direction and extends to the second vertical line;

a sixth conductive layer formed on part of the second dielectric layer, wherein a layout of the sixth

conductive layer starts from the fourth vertical line along the fourth horizontal line in the second direction and extends the third vertical line;

a seventh conductive layer formed on part of the second dielectric layer, wherein a layout of the seventh conductive layer starts from the first vertical line along the third horizontal line and extends to the fourth vertical line;

a eighth conductive layer formed on part of the dielectric layer, wherein a layout of the eight conductive layer starts from the first vertical line along the second horizontal line in the first direction and extends to the second vertical line;

a ninth conductive layer formed on part of the second dielectric layer, and a layout of the ninth conductive layer starts from the fourth vertical line along the second horizontal line in the second direction and extends the third vertical line;

a tenth conductive layer formed on part of the second dielectric layer, and a layout of the tenth conductive layer starts from the first vertical line along the first horizontal line and extends to the fourth vertical line;

a first conductive plug formed on an intersection of the second vertical line and the second horizontal line to penetrate the first dielectric layer and the second dielectric layer to electrically connected to the first conductive layer and the eighth conductive layer;

a second conductive plug formed on an intersection of the third vertical line and the second horizontal line to penetrate the second dielectric layer to electrically connected to the third conductive layer and the ninth conductive layer;

a third conductive plug formed on an intersection of the second vertical line and the fourth horizontal line to penetrate the second dielectric layer to electrically connected to the fourth conductive layer and the fifth conductive layer;

a fourth conductive plug formed on an intersection of the third vertical line and the fourth horizontal line to penetrate the first dielectric layer and the second dielectric layer to electrically connected to the second conductive layer and the sixth conductive layer;

a first laser spot formed on the fifth conductive layer;

a second laser spot formed on the sixth conductive layer;

a third laser spot formed on the second laser spot of the seventh conductive layer;

a fourth laser spot formed on the eighth conductive layer;

a fifth laser spot formed on the ninth conductive layer; and

a sixth laser spot formed on the fourth laser spot of the tenth conductive layer, wherein in the first conductive layer is electrically connected to the eighth conductive layer is a fuse unit, the third conductive layer is electrically connected to the ninth conductive layer is a fuse unit, the fourth conductive layer is electrically connected to the

fifth conductive layer is a fuse unit, the second conductive is electrically connected to the sixth conductive layer is a fuse unit, the seventh conductive layer is a fuse unit, the tenth conductive layer is a fuse unit.

8. The fuse window according to claim 7, wherein the first horizontal line, the second horizontal line, the third horizontal line, the fourth horizontal line and the fifth horizontal line are arranged in order, the first vertical line, the second vertical line, the third vertical line and the fourth vertical line are arranged in order, the distance between the first vertical line and the second vertical line longer than the distance between the second vertical line and the third vertical line, and the distance between the third vertical line and the fourth vertical line is longer than the distance between the second vertical line and the third vertical line.

9. The fuse window as claimed in claim 7, wherein the first conductive layer, the second conductive layer, the third conductive layer and the fourth conductive layer are tungsten or polysilicon.

10. The fuse window as claimed in claim 7, wherein the fifth conductive layer, the sixth conductive layer, the seventh conductive layer, the eighth conductive layer, the ninth conductive layer and tenth conductive layer are aluminum, copper-aluminum alloy or polysilicon.

11. The fuse window as claimed in claim 7, wherein the first conductive plug, the second conductive plug, the third conductive plug and the fourth conductive plug are tungsten or polysilicon.

12. The fuse window as claimed in claim 7, wherein the first dielectric layer and the second dielectric layer are $SiO_2$.

13. A fuse structure comprising:

a substrate;

an eleventh conductive layer formed on part of the substrate, wherein a layout of the eleventh conductive layer starts from a fourth horizontal line along a first vertical line and extends to a second horizontal line along a second horizontal line, turning in a third vertical line;

a twelfth conductive layer formed on part of the substructure, wherein a layout of the twelfth conductive layer starts from a fourth horizontal line along a seventh vertical line and extends to the second horizontal line along the second horizontal line, turning in a fifth vertical line;

a thirteenth conductive layer formed on part of the substrate, wherein a layout of the thirteenth conductive layer starts from a second vertical line along a third horizontal line and extends near to a fourth vertical line along the fourth vertical line, turning in a first horizontal line;

a fourteenth conductive layer formed on part of the substrate, wherein a layout of the fourteenth conductive layer starts from a sixth vertical line along the third horizontal line and extends to the fourth vertical line along the fourth vertical line, turning in the first horizontal line;

a first dielectric layer formed on the eleventh conductive layer, the twelfth conductive layer, the thirteenth conductive layer, the fourteenth conductive layer and part of the substrate;

a fifteenth conductive layer formed on part of the first dielectric, wherein a layout of the fifteenth conductive layer starts from the first vertical line along the second horizontal line and extends near to a second vertical line;

a sixteenth conductive layer formed on part of the first dielectric layer, wherein a layout of the sixteenth conductive layer starts from a seventh vertical line along the second horizontal line and extends near to a sixth vertical line;

a seventeenth conductive layer formed on part of the first dielectric layer, wherein a layout of the seventeenth conductive layer starts from a third vertical line along the third horizontal line and extends near to the fourth vertical line along the fourth vertical line, turning in the first horizontal line;

an eighteenth conductive layer formed on part of the first dielectric layer, wherein a layout of the eighteenth conductive layer starts from a fifth vertical line along the third horizontal line and extends near to the fourth vertical line along the fourth vertical line, turning in the first horizontal line;

a second dielectric layer formed on the fifteenth conductive layer, the sixteenth conductive layer, the seventeenth conductive layer, the eighteenth

conductive layer and part of the first dielectric layer;

a nineteenth conductive layer formed on part of the second dielectric layer, wherein a layout of the ninth conductive starts from the first horizontal line along the second vertical line and extends to the second horizontal line;

a twentieth conductive layer formed on part of the dielectric layer, wherein a layout of the twentieth conductive layer starts from the first horizontal line along the third vertical line and extends to the second horizontal line;

a twenty first conductive layer formed on part of the second dielectric layer, wherein a layout of the twenty first conductive layer starts from the fourth horizontal line along the second vertical line and extends to the third horizontal line;

a twenty second conductive layer formed on part of the second dielectric layer, wherein a layout of the twenty second conductive layer starts from the fourth horizontal line along the third vertical line and extends to the third horizontal line;

a twenty third conductive layer formed on part of the second dielectric layer, wherein a layout of the twenty third conductive layer starts from the first horizontal line along the fourth vertical line and extends to the fourth horizontal line;

a twenty fourth conductive layer formed on part of the dielectric layer, wherein a layout of the twenty fourth conductive layer starts from the fourth

horizontal line along the fifth vertical line and extends to the third horizontal line;

a twenty fifth conductive layer formed on part of the second dielectric layer, wherein a layout of the twenty fifth conductive layer starts from the fourth horizontal line along the sixth vertical line and extends to the third horizontal line;

a twenty sixth conductive layer formed on part of second the dielectric layer, wherein a layout of the twenty sixth conductive starts from the first horizontal line along the fifth vertical line and extends to the second horizontal line;

a twenty seventh conductive layer formed on part of the second dielectric layer, wherein a layout of the twenty seventh conductive layer starts from the first horizontal line along the sixth vertical line and extends to the second horizontal line;

a twenty eighth conductive layer formed on part of the second dielectric layer, wherein a layout of the twenty eighth conductive layer starts from the first horizontal line along the seventh vertical line and extends to the fourth horizontal line;

a eleventh conductive plug formed on an intersection of the second vertical line and the second horizontal line to penetrate the second dielectric layer to electrically connected to the fifteenth conductive layer and the nineteenth conductive layer;

a twelfth conductive plug formed on an intersection of the third vertical line and the second horizontal line to penetrate the first dielectric layer and the

second dielectric layer to electrically connected to the eleventh conductive layer and twentieth conductive layer;

a thirteenth conductive plug formed on an intersection of the fifth vertical line and the second horizontal line to penetrate the first dielectric layer and the second dielectric layer to electrically connected to the twelfth conductive layer and the twenty sixth conductive layer;

a fourteenth conductive plug formed on an intersection of the sixth vertical line and the second horizontal line to penetrate the second dielectric layer to electrically connected to the sixteenth conductive layer and twenty seventh conductive layer;

a fifteenth conductive plug formed on an intersection of the second vertical line and the third horizontal line to penetrate the first dielectric layer and the second dielectric layer to electrically connected to the thirteenth conductive layer and the twenty first conductive layer;

a sixteenth conductive plug formed on an intersection of the third vertical line and the third horizontal line to penetrate the second dielectric layer to electrically connected to the seventeenth conductive layer and twenty second conductive layer;

a seventeenth conductive plug formed on an intersection of the fifth vertical line and the third horizontal line to penetrate the second dielectric layer to electrically connected to the eighteenth conductive layer and twenty fourth conductive layer; and

an eighteenth conductive plug formed on an intersection of the sixth vertical line and the third horizontal line to penetrate the first dielectric layer and the second dielectric layer to electrically connected to the fourteenth conductive layer and the twenty fifth conductive layer.

14. The fuse structure according to claim 13, wherein the seventeenth conductive layer, the twentieth conductive layer, the thirteenth conductive layer and the fourteenth conductive layer are tungsten or polysilicon.

15. The fuse structure according to claim 13, wherein the fifteenth conductive layer, the sixteenth conductive layer, the seventeenth conductive layer, and the eighteenth conductive layer are tungsten or polysilicon.

16. The fuse structure according to claim 13, wherein the nineteenth conductive layer, the twentieth conductive layer, the twenty first conductive layer, the twenty second conductive layer, the twenty third conductive layer, the twenty fourth conductive layer, the twenty fifth conductive layer, the twenty sixth conductive layer, the twenty seventh conductive layer and the twenty eighth conductive layer are aluminum, copper-aluminum alloy or polysilicon.

17. The fuse structure according to claim 13, wherein the seventh conductive plug, the twelfth conductive plug, the thirteenth conductive plug, the fourteenth conductive plug, the fifteenth conductive plug, the sixteenth conductive plug, the

seventeenth conductive plug and the eighteenth conductive plug are tungsten or polysilicon.

18. The fuse structure according to claim 13, wherein the first dielectric layer and the second dielectric layer are $SiO_2$.

19. A fuse window comprising:

a substrate;

an eleventh conductive layer formed on part of the substrate, wherein a layout of the eleventh conductive layer starts from a fourth horizontal line along a first vertical line and extends to a second horizontal line along a second horizontal line, turning in a third vertical line;

a twelfth conductive layer formed on part of the substructure, wherein a layout of the twelfth conductive layer starts from a fourth horizontal line along a seventh vertical line and extends to the second horizontal line along the second horizontal line, turning in a fifth vertical line;

a thirteenth conductive layer formed on part of the substrate, wherein a layout of the thirteenth conductive layer starts from a vertical line along a third horizontal line and extends near to a fourth vertical line along a fourth vertical line, turning in a first horizontal line;

a fourteenth conductive layer formed on part of the substrate, wherein a layout of the fourteenth conductive layer starts from a sixth vertical line along the third horizontal line and extends to the

fourth vertical line along the fourth vertical line, turning in the first horizontal line;

a first dielectric layer formed on the eleventh conductive layer, the twelfth conductive layer, the thirteenth conductive layer, the fourteenth conductive layer and part of the substrate;

a fifteenth conductive layer formed on part of the first dielectric, wherein a layout of the fifteenth conductive layer starts from the first vertical line along the second horizontal line and extends to a second vertical line;

a sixteenth conductive layer formed on part of the first dielectric layer, wherein a layout of the sixteenth conductive layer starts from a seventh vertical line along the second horizontal line and extends to a sixth vertical;

a seventeenth conductive layer formed on part of the first dielectric layer, wherein a layout of the seventeenth conductive layer starts from a third vertical line along the third horizontal line and extends near to the fourth vertical line along the fourth vertical line, turning in the first horizontal line;

an eighteenth conductive layer formed on part of the first dielectric layer, wherein a layout of the eighteenth conductive layer starts from a fifth vertical line along the third horizontal line and extends near to the fourth vertical line along the fourth vertical line, turning in the first horizontal line;

a second dielectric layer formed on the fifteenth conductive layer, the sixteenth conductive layer,

the seventeenth conductive layer, the eighteenth conductive layer and part of the first dielectric layer;

a nineteenth conductive layer formed on part of the second dielectric layer, wherein a layout of the ninth conductive starts from the first horizontal line along the second vertical line and extends to the second horizontal line;

a twentieth conductive layer formed on part of the dielectric layer, wherein a layout of the twentieth conductive layer starts from the first conductive layer along the third vertical line and extends to the second horizontal line;

a twenty first conductive layer formed on part of the second dielectric layer, wherein a layout of the twenty first conductive layer starts from the fourth horizontal line along the second vertical line and extends to the third horizontal line;

a twenty second conductive layer formed on part of the second dielectric layer, wherein a layout of the twenty second conductive layer starts from the fourth horizontal line along the third vertical line and extends to the third horizontal line;

a twenty third conductive layer formed on part of the second dielectric layer, wherein a layout of the twenty third conductive layer starts from the first horizontal line along the fourth vertical line and extends to the fourth horizontal line;

a twenty fourth conductive layer formed on part of the dielectric layer, wherein a layout of the twenty

fourth conductive layer starts from the fourth horizontal line along the fifth vertical line and extends to the third horizontal line;

a twenty fifth conductive layer formed on part of the second dielectric layer, wherein a layout of the twenty fifth conductive layer starts from the fourth horizontal line along the sixth vertical line and extends to the third horizontal line;

a twenty sixth conductive layer formed on part of second the dielectric layer, wherein a layout of the twenty sixth conductive starts from the first horizontal line along the fifth vertical line and extends to the second horizontal line;

a twenty seventh conductive layer formed on part of the second dielectric layer, wherein a layout of the twenty seventh conductive layer starts from the first horizontal line along the sixth vertical line and extends to the second horizontal line;

a twenty eighth conductive layer formed on part of the second dielectric layer, wherein a layout of the twenty eighth starts from the first horizontal line along the seventh vertical line and extends to the fourth horizontal line;

a eleventh conductive plug formed on an intersection of the second vertical line and the second horizontal line to penetrate the second dielectric layer to electrically connected to the fifteenth conductive layer and the nineteenth conductive layer;

a twelfth conductive plug formed on an intersection of the third vertical line and the second horizontal line

to penetrate the first dielectric layer and the second dielectric layer to electrically connect the eleventh conductive layer and twentieth conductive layer;

a thirteenth conductive plug formed on an intersection of the fifth vertical line and the second horizontal line to penetrate the first dielectric layer and the second dielectric to electrically connected to the twelfth conductive layer and the twenty sixth conductive layer;

a fourteenth conductive plug formed on an intersection of the sixth vertical line and the second horizontal line to penetrate the second dielectric layer to electrically connected to the sixteenth conductive layer and twenty seventh conductive layer;

a fifteenth conductive plug formed on an intersection of the second vertical line and the third horizontal line to penetrate the first dielectric layer and the second dielectric layer to electrically connected to the thirteenth conductive layer and the twenty first conductive layer;

a sixteenth conductive plug formed on an intersection of the third vertical line and the third horizontal line to penetrate the second dielectric layer to electrically connected to the seventeenth conductive layer and twenty second conductive layer;

a seventeenth conductive plug formed on an intersection of the fifth vertical line and the third horizontal line to penetrate the second dielectric layer to

electrically connected to the eighteenth conductive layer and twenty fourth conductive layer; and

a eighteenth conductive plug formed on an intersection of the sixth vertical line and the third horizontal line to penetrate the first dielectric layer and the second dielectric layer to electrically connected to the fourteenth conductive layer and the twenty fifth conductive layer;

an eleventh laser spot formed on the nineteenth conductive layer;

a twelfth laser spot formed on the twentieth conductive layer;

a thirteen laser spot formed on the twenty first conductive layer;

a fourteenth laser spot formed on the twenty second conductive layer;

a fifteenth laser spot formed on the twenty third conductive layer;

a sixteenth laser spot formed on the twenty fourth conductive layer;

a seventeenth laser spot formed on the twenty fifth conductive layer;

a eighteenth laser spot formed on the twenty sixth conductive layer;

a nineteenth laser spot formed on the twenty seventh conductive layer; and

a twentieth laser spot formed on the twenty eighth conductive layer;

wherein in the fuse window comprises a plurality of fuse structures, each fuse structure comprising ten

fuses, each with its own laser spot, and not electrically connected to each other, wherein the fifteenth conductive layer is electrically connected to the nineteenth conductive layer is a fuse unit, the eleventh conductive layer is electrically connected to the twentieth conductive layer is a fuse unit, the twelfth conductive layer is electrically connected to the twenty sixth conductive layer is a fuse unit, the sixteenth conductive layer is electrically connected to the twenty seventh conductive layer is a fuse unit, the thirteenth conductive layer is electrically connected to the twenty first conductive layer is a fuse unit, the seventeenth conductive layer is electrically connected to the twenty second conductive layer is a fuse unit, the eighteenth conductive layer is electrically connected to the twenty fourth conductive layer is a fuse unit, the fourteenth conductive layer is electrically connected to the twenty fifth conductive layer is a fuse unit, the twenty third conductive layer is a fuse unit, and a twenty eighth conductive layer is a fuse unit.

20. The fuse window according to claim 19, wherein the eleventh conductive layer, the twelfth conductive layer, thirteenth conductive layer, and fourteenth conductive layer are tungsten or polysilicon.

21. The fuse window according to claim 19, wherein the

fifteenth conductive layer, the sixteenth conductive layer, the seventeenth conductive layer, and the eighteenth conductive layer are tungsten or polysilicon.

22. The fuse window according to claim 19, wherein the nineteenth conductive layer, the twentieth conductive layer, the twenty first conductive layer, the twenty second conductive layer, the twenty third conductive layer,, the twenty fourth conductive layer, the twenty fifth conductive layer, the twenty sixth conductive layer, twenty seventh conductive layer and the twenty eighth conductive layer are aluminum, copper-aluminum alloy or polysilicon.

23. The fuse window according to claim 19, wherein the eleventh conductive plug, the twelfth conductive plug, the thirteenth conductive plug, the fourteenth conductive plug, the fifteenth conductive plug, the sixteenth conductive plug, the seventeenth conductive plug and the eighteenth conductive plug are tungsten or polysilicon.

24. The fuse window according to claim 19, wherein the first dielectric layer and the second dielectric layer are SiO2.

25. A processing method for fuse structure, comprising the steps of:

providing a structure;

forming a first conductive layer and a second conductive layer on part of the structure;

forming a first dielectric layer on the first conductive layer, the second conductive layer and the structure;

forming a first opening on the first dielectric layer, exposing the first conductive layer and the second conductive layer;

implanting a first conductive plug to penetrate the first conductive layer via the first opening;

forming a third conductive layer and a fourth conductive layer on part of the first dielectric layer;

forming a second dielectric layer on the third conductive layer, the fourth conductive layer and the first dielectric layer;

forming a second opening on the second dielectric layer, exposing the first opening, the third conductive layer and the fourth conductive layer;

implanting the second conductive plug to penetrate the second dielectric layer via the second opening;

forming a fifth conductive layer, a sixth conductive layer, a seventh conductive layer, a eighth conductive layer, a ninth conductive layer and a tenth conductive layer on part of the second dielectric layer, wherein a third conductive plug is electrically connected to the fourth conductive layer and the fifth conductive layer, a fourth conductive plug is electrically connected to the second conductive layer and the sixth conductive layer, the third conductive layer is electrically connected to the ninth conductive layer and the eighth conductive layer is electrically connected to the first conductive layer.

26. A processing method for fuse structure, comprising the steps of:

forming a substrate;

forming a eleventh conductive layer, a twelfth conductive layer, a thirteenth conductive layer and a fourteenth conductive layer on part of the substrate;

forming a first dielectric layer on the eleventh conductive layer, the twelfth conductive layer, the thirteenth conductive layer, the fourteenth conductive layer and the substrate;

forming a fifteenth conductive layer, a sixteenth conductive layer, a seventeenth conductive layer, a eighteenth conductive layer on part of the first dielectric layer;

forming a second dielectric layer on the fifteenth conductive layer, the sixteenth conductive layer, the seventeenth conductive layer, the eighteen conductive layer and the first dielectric layer;

forming an opening on the first dielectric layer and second dielectric layer, exposing the eleventh conductive layer, the twelfth conductive layer, the thirteenth conductive layer, fourteenth conductive layer, fifteenth conductive layer, the sixteenth conductive layer, the seventeenth conductive layer and the eighteenth conductive layer;

implanting a conductive plug in the opening, to penetrate the first dielectric layer and the second dielectric layer; and

forming a nineteenth conductive layer, a twentieth conductive layer, a twenty first conductive layer, twenty second conductive layer, a twenty third conductive layer, a twenty fourth conductive layer,

a twenty fifth conductive layer, a twenty sixth conductive layer, a twenty seventh conductive layer and a twenty eighth conductive layer on part of the second dielectric layer, wherein a eleventh conductive plug is electrically connected to the fifteenth conductive layer and nineteenth conductive layer, a twelfth conductive plug is electrically connected to the eleventh conductive layer and the twentieth conductive layer, a thirteenth conductive plug is electrically connected to the twenty sixth conductive layer and the twelfth conductive layer, a fourteenth conductive plug is electrically connected to the twenty seventh conductive layer and the sixteenth conductive layer, a fifteenth conductive plug is electrically connected to the twenty first conductive layer and the thirteenth conductive layer, a sixteenth conductive layer is electrically connected to the twenty second conductive layer and the seventeenth conductive layer, a seventeenth plug is electrically connected to the twenty fourth conductive layer and eighteenth conductive layer, and a eighteenth conductive plug is electrically connected to the twenty fifth conductive layer and the fourteenth conductive layer.